

EXTENDED SUBMISSION DEADLINE—August 1, 2016



## Aberration Corrected Transmission Electron Microscopy

Spherical and chromatic aberration correctors in transmission and in scanning transmission electron microscopes (TEM/STEM) have become commercially available in recent years. They are comprised of electromagnetic multipoles driven by ultra-stable power supplies in conjunction with faster and more efficient hard- and software for image acquisition, analysis, and alignment. This technology has significantly improved the spatial resolution, down to the size of the Bohr radius under certain conditions so that the atomic scattering in the sample can limit the resolution, rather than the microscope.

Focus now needs to shift towards new scientific areas that can be addressed with this novel equipment, taking into account the improved resolution, reduced thermal drift, novel electron detectors, and larger pole-piece gaps, due directly or indirectly to the advent of aberration correction. The parameter space for operation has become much more complex, so operators need to carefully plan experiments to find the best way to extract meaningful data. In particular, the high voltage should be optimized to minimize radiation damage. Better resolution may involve higher electron doses but imply more beam damage. Increased stability allows fast experiments with highly focused electron probes. More sensitive detectors can be used to test new data acquisition schemes as well as to reduce the electron dose. Consideration must be given as to whether the fascinating *in-situ* studies of the kinetics of atomic growth mechanisms now possible will allow meaningful inference to be drawn on thermodynamic properties representative of the bulk. *In-operando* studies of specimens in their engineered application environment (i.e. in gaseous or liquid atmosphere, under electrical bias, strain, illumination, etc.) can be conducted at nano-scale resolution.

This Focus Issue will include imaging, spectroscopy, and diffraction based (S)TEM applications to materials science problems with planar or focused illumination.

Contributed articles are particularly sought in the following areas:

- ◆ Resolution vs. quantification issues in quantitative high-resolution imaging
- ◆ Quantitative spectroscopy for local measurements of chemistry or electronic properties
- ◆ Limitations due to radiation damage
- ◆ Comparing studies by planar and focused illumination: evaluating dose vs. dose rate effects
- ◆ Applications of chromatic aberration correction, monochromation, and low energy studies
- ◆ Applications of improved electron detectors and novel acquisition schemes
- ◆ *In-situ* strain measurements and *in-operando* catalysis studies

### GUEST EDITORS

**Thomas Walther**, University of Sheffield, United Kingdom

**Rafal E. Dunin-Borkowski**, Ernst Ruska-Centre, Research Centre Jülich, Germany

**Jean-Luc Rouviere**, CEA Grenoble, France

**Eric A. Stach**, Brookhaven National Laboratory

### MANUSCRIPT SUBMISSION

To be considered for this issue, new and previously unpublished results significant to the development of this field should be presented. The manuscripts must be submitted via the *JMR* electronic submission system by **August 1, 2016**. Manuscripts submitted after this deadline will not be considered for the issue due to time constraints on the review process. **Submission instructions may be found at [www.mrs.org/jmr-instructions](http://www.mrs.org/jmr-instructions)**. Please select "Focus issue: *Aberration Corrected Transmission Electron Microscopy*" as the manuscript type. **Note our manuscript submission minimum length of 6000 words.** All manuscripts will be reviewed in a normal but expedited fashion. Papers submitted by the deadline and subsequently accepted will be published in the Focus Issue. Other manuscripts that are acceptable but cannot be included in the issue will be scheduled for publication in a subsequent issue of *JMR*.

**[jmr@mrs.org](mailto:jmr@mrs.org)**  
Please contact [jmr@mrs.org](mailto:jmr@mrs.org) with questions.

CALL FOR PAPERS

# MATERIALS RESEARCH SOCIETY®

## 2016 Board of Directors

### Officers

Kristi S. Anseth, *President*  
Oliver Kraft, *Past President*  
Susan Trolier-McKinstry, *Vice President*  
Sean J. Hearne, *Secretary*  
David J. Parrillo, *Treasurer*  
Todd M. Osman, *Executive Director*

### Directors

Charles T. Black  
Alexandra Boltasseva  
C. Jeffrey Brinker  
Matt Copel  
Paul Drzaic  
Yury Gogotsi  
Hideo Hosono  
Young-Chang Joo  
Karen L. Kavanagh  
Kornelius Nielsch  
Christine Ortiz  
Sabrina Sartori  
Magaly Spector  
Loucas Tsakalakos  
Anke Weidenkaff

## 2016 Publications Committee

R.A. Vaia, *Chair*  
S.P. Baker, *Editors Subcommittee*  
A.J. Hurd, *New Publication Products Subcommittee*  
R.J. Nemanich, *Publications Quality Subcommittee*

## 2016 MRS Committee Chairs

B.M. Clemens, *Academic Affairs*  
A. Polman, *Awards*  
K. Whittlesey, *Government Affairs*  
D.S. Ginley, *Meetings*

Y. Chabal, *Member Engagement*  
E. Kupp, *Public Outreach*  
R.A. Vaia, *Publications*

## MRS Headquarters

T.M. Osman, *Executive Director*  
J.A. Dillen, *Director of Finance and Administration*  
D. Dozier, *Director of Government Affairs*  
P.A. Hastings, *Director of Meeting Activities*  
E.M. Kiley, *Director of Communications*

## Journal of Materials Research Founding Sponsors

Allied-Signal Inc.  
Xerox Corporation

## About the Materials Research Society

The Materials Research Society (MRS®) is a not-for-profit scientific association founded in 1973 to promote interdisciplinary goal-oriented basic research on materials of technological importance. Membership in the Society includes over 16,000 scientists from industrial, government, and university research laboratories in the United States and abroad.

The Society's interdisciplinary approach to the exchange of technical information is qualitatively different from that provided by single-discipline professional societies because it promotes technical exchange across the various fields of science affecting materials development. MRS sponsors two major international annual meetings encompassing many topical symposia, as well as numerous single-topic scientific meetings each year. It recognizes professional and technical excellence, conducts tutorials, and fosters technical exchange in various local geographical regions through Section activities and Student Chapters on university campuses.

Disclaimer: Authors of each article appearing in this Journal are solely responsible for all contents in their article(s) including accuracy of the facts, statements, and citing resources. Facts and opinions are solely the personal statements of the respective authors and do not necessarily represent the views of the editors, the Materials Research Society, or Cambridge University Press.

MRS journals maintain a proud tradition of editorial excellence in scientific literature. The *Journal of Materials Research*, the archival journal spanning fundamental developments in materials science, is published twenty-four times a year by MRS and Cambridge University Press. *MRS Bulletin* is a premier source for comprehensive research trends and a timely scan of professional activities. *MRS Communications* is a full-color letters and perspectives journal focused on groundbreaking work across the spectrum of materials research. *MRS Energy & Sustainability—A Review Journal* publishes reviews on key topics in materials research and development as they relate to energy and sustainability. *MRS Advances* is a peer-reviewed online-only journal featuring impactful and emerging research, designed to reflect the way materials researchers work, write, publish and share their results.

The *Journal of Materials Research* is free electronically to all MRS regular and student members. See inside front cover for subscription rates for *Journal of Materials Research*.

MRS is an Affiliated Society of the American Institute of Physics and participates in the international arena of materials research through associations with professional organizations.

For further information on the Society's activities, contact MRS Headquarters, 506 Keystone Drive, Warrendale, PA 15086-7573; telephone (724) 779-3003; fax (724) 779-8313.



Postmaster—Send change of address notice to:

Cambridge University Press  
One Liberty Plaza, 20th Floor,  
New York, NY 10006

A publication of the  
**MRS** MATERIALS RESEARCH SOCIETY  
*Advancing materials. Improving the quality of life.*

Periodical Rate Postage Paid at New York, NY  
and Additional Mailing Offices

ISSN: 0884-2914